

The Institute of Photonic Sciences

Nano-optoelectronics Group

www.koppensgroup.icfo.eu

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March 11th 2015

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Electrical control of interaction





Vakil and Engheta, Science (2011)

Alonso-Gonzalez et al, Science (2014)

Active plasmonics



e-h pair excitation Absorber photon emission Transparent plasmon launching Metallic







LDOS (a.u.)

Far-field vs. near-field

k = 0





Nair et al, Science (2008)

Far-field vs. near-field

k = 0





Nair et al, Science (2008)



k > 0

- Forster resonant energy transfer
- Plasmon launching
- Electrical tunability

Swathi, JCP (2009) Gomez-Santos et al. PRB (2011) Koppens et al, Nano Lett. (2011) Nikitin et al, PRB (2011) Velizhanin and Efimov, PRB (2011)

Absorber: experimental





<u>10 μm</u>



Z. Chen et al., ACS Nano (2010)

L. Gaudreau et al., Nanoletters (2013)



Absorber: experimental



10 µm



Z. Chen et al., ACS Nano (2010)

L. Gaudreau et al., Nanoletters (2013) Gomez-Santos et al. PRB (2011)







Non-radiative energy transfer





Absorber





Absorber



Absorber





Gomez-Santos, PRB (2011) Swathi et al., JCP (2009) Huang et al., Small (2012) Brenneis et al., Nature Nanotech. (2014)



Electrical read-out



Brenneis et al., Nature Nanotech. (2014)



Jelezko and Wrachtrup, (2006) Brenneis et al., Nature Nanotech. (2014)



Brenneis et al., Nature Nanotech. (2014)



• energy transfer

-0.5

2.80

2.85

f_{MW} (GHz)

2.90

• the NV spin state

Brenneis et al., Nature Nanotech. (2014)





Device





Erbium emission at 1530 nm: *E_{em} = 0.8 eV*

KJT et al., Nature Phys. (2015)

Device



Fluorescence quenching



Fluorescence quenching







Electrostatic control



 $6.1 \qquad \text{Emission (10³ counts/s)} \qquad 1.9$

e-h pair excitation Absorber





photon emission *Transparent*



 E_{F}



Gate-tunable decay rate



Comparison with model







Joulain et al, PRB (2003) Novotny and Hecht (2006) Koppens et al. Nano Lett. (2011) Gomez-Santos et al. PRB (2011) Koppens et al, Nano Lett. (2011) Nikitin et al, PRB (2011) Velizhanin and Efimov, PRB (2011)

Comparison with model



Graphene plasmons



Ju et al. Nature Nanotech. (2011)

•••

Graphene plasmons



























Strongly confined plasmons (<15 nm) plasmon launching *Metallic*



Conclusion



Outlook







Plasmonics



Telecommunications



Outlook









 Erbium
 Diamond NV centers
 Quantum Dots
 Fluorescent molecules





Acknowledgements



The Institute of Photonic Sciences





Prof. Frank Koppens

 Nano-optoelectronics Group

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 Fundació Privada

 CEELEEX

 European Regional

 Development Fund

 European Regional

 Development Fund

 European Regional

 European Regional

Graphenea, Spain Amaia Zurutuza Amaia Pesquera Alba Centeno ICFO, Spain Javier Garcia de Abajo Michela Badioli Gabriele Navickaite Simon Coop Louis Gaudreau Hugues de Riedmatten

MIT, USA Lucas Orona Qiong Ma Pablo Jarillo-Herrero

Chimie Paris Tech, France Alban Ferrier **Philippe Goldner**

Padova, Italy Boris Kalinic



Conclusion

